FORM PTO-1449 (Modified) LISTING PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)	ATTY. DOCKET NO. 00750479AA	SERIAL NO. 10/684,596
	APPLICANTS: A. Chakravarti, et al.	
	FILING DATE: October 15, 2003	GROUP: 2812

OIPE FEB 09 2004 JC89 U.S. PATENT & TRADEMARK OFFICE

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

EXAMINER INITIALS		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPRO.)
		6,268,299	7/31/01	R. Jammy, et al.			9/25/00
		6,486,015	11/26/02	N. Chaudhary, et al.			4/25/00
		6,500,772	12/31/02	A. Chakravarti, et al.			01/08/01
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		6,518,626	02/11/03	J. Moore			02/22/00

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES	TRANSLATION NO

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

		Jalabert, L.; et al., Reduction of boron penetration through thin silicon oxide with a nitrogen doped silicon layer; Pergamon; Microelectronics Reliability 41 (2001) 981-985

EXAMINER Saeed Kahn DATE CONSIDERED 2/20/05

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.